Complete Listing of Claims

1.-7. (Cancelled)

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8. (Original) A method for manufacturing a glass substrate of an information recording medium by polishing a surface of a glass workpiece with a polishing pad,

wherein polishing includes a first polishing step for subjecting a surface of the glass workpiece to rough polishing, and a second polishing step for subjecting the surface of the glass workpiece to precision polishing so that the surface is further smoothed,

wherein the polishing pad is used in a second polishing step.

- 9. (Original) The method according to claim 8, wherein the number of pores on the polishing pad is 400 to 10,000 in 1 mm².
- 10. (Original) The method according to claim 8, wherein the compression deformation amount of the polishing pad is 40 to 60 μm.
- 11. (Original) The method according to claim 8, wherein the opening sizes of the pores are 10 to $60 \mu m$.
- 12. (Original) The method according to claim 8, wherein the glass workpiece is one of a plurality of glass workpieces that are simultaneously polished, wherein the variation of the thickness of removal layers of the glass workpieces is equal to or less than $0.2 \mu m$.
- 13. (Original) A glass substrate of an information recording medium, manufactured by the method according to claim 8,

wherein, when measured with a three-dimensional external structure analysis microscope at a wavelength (λ) of 0.2 to 1.4 mm, the height (NRa) of micro-waviness on the surface is equal to or less than 0.15 nm.

14. (Cancelled)